

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings of claims in the application:

Listing of Claims:

- 1 1. (Currently Amended) A metal identification platelet (1) equipped with an
2 identification code, ~~characterized by the fact, that~~ wherein the identification code comprises a
3 hologram (2).

- 1 2. (Currently Amended) The metal identification platelet (1) as in Claim 1,
2 ~~characterized by the fact, that~~ wherein the identification code further comprises a passage
3 shape hole (3), and/or the identification code is constituted by an external shape of the platelet
4 (1).

- 1 3. (Currently Amended) The metal identification platelet (1) as in Claim 2,
2 ~~characterized by the fact, that~~ wherein the hologram (2) and/or shape hole (3) comprises ~~of an~~
3 alphanumeric characters.

- 1 4. (Currently Amended) The metal identification platelet (1) as in ~~any of the~~
2 ~~Claims 1 to 3, characterized by the fact, that~~ wherein the metal ~~used~~ is nickel, with a thickness
3 of 1 to 15 µm thick.

- 1 5. (Currently Amended) A method of producing an identification platelet (1)
2 with ~~the~~ an identification code, ~~characterized by the fact, that it comprises the following~~
3 ~~steps~~ the method comprising:
4 forming a shield (9) from an electro-insulation material ~~is formed~~ on a shim (4)
5 with a holographic motif (7),
6 then, galvanizing the shim (4) ~~is galvanized~~ in ~~the~~ places not covered by the
7 shield (9) from the electro-insulation material, and

8 and removing the completed metal identification platelets **(1)** ~~are removed~~ from
9 the shim **(4)**.

1 6. (Currently Amended) The method as in Claim 5, **characterized by the fact,**
2 ~~that~~ wherein forming the shield **(9)** from the electro-insulation material ~~is produced in the~~
3 following way comprises:

4 applying a photoresist layer **(5)** ~~is applied~~ on the shim **(4)** with a holographic
5 motif **(7)**,

6 then putting a mask **(6)** ~~is put~~ on the photoresist layer **(5)**, **and**
7 exposing the photoresist layer **(5)** with the mask **(6)** ~~is exposed~~ by a UV lamp,
8 **and**

9 etching the exposed photoresist layer **(5)** ~~is etched~~ from the shim **(4)** in a
10 developer,

11 than then galvanizing the shim **(4)** ~~is galvanized~~ in the places where the
12 photoresist layer **(5)** was etched,

13 removing the waste photoresist layer **(5)** ~~is removed~~, **and**
14 and taking the completed metal identification platelets **(1)** ~~are taken~~ from the
15 shim **(4)**.

1 7. (Currently Amended) The method as in Claim 5 ~~or 6~~, **characterized by the**
2 **fact, that** further comprising passivating the shim **(4)** ~~is passivated~~ by the a solution of
3 potassium dichromate.

1 8. (Currently Amended) The method as in ~~any of the~~ Claims 6 ~~to~~ 7,
2 **characterized by the fact, that** wherein the mask comprises a printing film ~~is used as the mask~~
3 **(6)**.

1 9. (Currently Amended) The method as in ~~any of the~~ Claims 5 ~~to~~ 8,
2 **characterized by the fact, that** wherein the shim **(4)** is galvanized in a galvanic-plastic nickel
3 bath.

1 10. (Currently Amended) The method as in ~~any of the~~ Claims 5 to 9,
2 ~~characterized by the fact, that~~ further comprising:
3 removing the ~~waste~~ shield (9) from the electro-insulation material and/or waste
4 photoresist layer (5) ~~is removed~~ by washing in a solvent, and
5 then washing the shim (4) ~~is washed~~ in ~~demineralised~~ demineralized water and
6 ~~dried~~ drying the shim.

1 11. (Currently Amended) The method as in ~~any of the~~ Claims 5 to 10,
2 ~~characterized by the fact, that~~ further comprising removing the completed metal identification
3 platelets (1) ~~are removed~~ from the shim (4) by fine scraping or in an ultrasonic bath.

1 12. (Currently Amended) The method as in ~~any of the~~ Claims 5 to 11,
2 ~~characterized by the fact, that~~ wherein the shim (4) with the holographic motif (7) is made
3 from nickel.

1 13. (Currently Amended) The method as in Claim 5, ~~characterized by the fact,~~
2 ~~that~~ further comprising applying the shield (9) from the electro-insulation material ~~is applied~~
3 directly on the shim (4) with the holographic motif (7) using a printing method.

1 14. (Currently Amended) The method as in Claim 13, ~~characterized by the~~
2 ~~fact, that~~ further comprising applying the shield (9) from the electro-insulation material ~~is~~
3 ~~applied~~ using the method of intaglio printing.